

EPO-TEK[®] H21D Technical Data Sheet For Reference Only Electrically Conductive, Silver Epoxy

Date:	February 2021		Recommended Cure: 150°C / 1 Hour
Rev:	X		
No. of Components:	Тwo		Minimum Alternative Cure(s):
Mix Ratio by Weight:	10 : 1		May not achieve performance properties listed below
Specific Gravity:	Part A: 2.45	Part B: 2.14	150°C / 5 Minutes
Pot Life:	15 Hours		120°C / 15 Minutes
Shelf Life- Bulk:	One year at room temperature		80°C / 90 Minutes

NOTES:

• Container(s) should be kept closed when not in use.

• Filled systems should be stirred thoroughly before mixing and prior to use.

• Performance properties (rheology, conductivity, others) of the product may vary from those stated on the data sheet when bi-pak/syringe packaging or post-processing of any kind is performed. Epoxy's warranties shall not apply to any products that have been reprocessed or repackaged from Epoxy's delivered status/container into any other containers of any kind, including but not limited to syringes, bi-paks, cartridges, pouches, tubes, capsules, films or other packages.

Product Description: EPO-TEK® H21D is a two component, high Tg, silver-filled epoxy designed for chip bonding in microelectronic and optoelectronic applications.

<u>Typical Properties:</u> Cure condition: 150°C / 1 Hour Different batches, conditions & applications yield differing results. Data below is not guaranteed. To be used as a guide only, not as a specification. * denotes test on lot acceptance basis

PHYSICAL PROPERTIES:					
* Color (before cure):	Part A: Silver	Part B: Silver			
* Consistency:	Smooth paste				
* Viscosity (23°C) @ 10 rpm:	25,000-40,00	0 cPs			
Thixotropic Index:	2	6			
* Glass Transition Temp:	≥ 10	0 °C (Dynamic Cure: 20-200°C/ISO 25 Min; Ramp -10-200°C @20°C/Min)			
Coefficient of Thermal Expansion (CTE):					
Below Tg:	4	2 x 10 ⁻⁶ in/in°C			
Above Tg:	22	25 x 10 ⁻⁶ in/in°C			
Shore D Hardness:		0			
Lap Shear @ 23°C:	1,50	l4 psi			
Die Shear @ 23°C:	≥ 1	0 Kg 3,556 psi			
Degradation Temp:	4	6 °C			
Weight Loss:					
@ 200°C:	0.0	3 %			
@ 250°C:	0.0	6 %			
@ 300°C:	0.1	7 %			
Suggested Operating Temperature:	< 3	0 °C (Intermittent)			
Storage Modulus:	802,4	1 psi			
Ion Content:	Cl ⁻ : 64 pp	m Na⁺: 72 ppm			
	NH4 ⁺ : 121 pp	m K⁺: ND ppm			
* Particle Size:	≤ 4	5 microns			
ELECTRICAL AND THERMAL PROPERTIES:					
Thermal Conductivity:	1	0 W/mK			
* Volume Resistivity @ 23°C:	≤ 0.000	9 Ohm-cm			

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EPO-TEK® H21D Advantages & Suggested Application Notes:

- Extended pot-life and can be cured at relatively low temperatures such as 80°C.
- Designed to be used in the 300°C range for applications such as wire bonding operations and eutectic lid-sealing processes.
- Contains no solvents or thinners. NASA approved, low outgassing epoxy <u>http://outgassing.nasa.gov/</u>
- Also suggested for hybrid aerospace circuits found in RF / Microwave devices like cockpits and satellites.
- Paste-like rheology allows for application by commercial dispensing equipment, stamping, screen printing, or by hand with spatula or toothpick.
- Compatible with Au-plated ceramic substrates found in traditional and custom hybrids.